Electronic supplementary information

Co-modification of WO³ nanoplates with ß-FeOOH/carbon quantum dots combined with plasma treatment enabling high-efficiency photoelectrochemical characteristics

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S1 Morphological investigations and correlated band diagram of WO_3 -nanoplate based photoanode

Fig. S1 (a) Cross-section SEM image of WO_3 NPs directly grown on FTO substrate.

(b) Schematic diagram of hole transport across interfaces between $WO₃$ NPs and electrolytes.

S2 XRD characterizations and LSV measurements of various $FeOOH@WO_3$ photoanodes

Fig. S2 XRD patterns of prepared β-FeOOH@WO3 NPs via four various synthetic durations.

Fig. S3 LSV curves of prepared β-FeOOH@WO3 NPs via three various synthetic durations. It should be pointed out that the photoanode reported here does not possess the capability to fully split water due to the employment of counter electrode [1-3].

S3 Featuring band diagram of $FeOOH@WO_3$ NPs with and without undergoing plasma treatment

Fig. S4 Schematic illustrations of band diagrams of hybrid $FeOOH@WO_3$ NPs (a) without plasma treatment and (b) with plasma treatment for 120 s.

S4 Morphological evolutions and chemical compositions of photoanodes under plasma treatment

Fig. S5 Representative HRTEM image of p-FeOOH@WO₃ NPs after undergoing 150 s of plasma treatment, where the distorted microstructures are evidenced.

Fig. S6 (a) Representative TEM image of p-FeOOH@WO₃ NPs after undergoing 120 s of plasma treatment, indicating that composite structures are retained without showing distorted features. Corresponding EDS elemental mappings p-FeOOH@WO3 NPs (120) s) of (b) W element, (c) O element and (d) Fe element, which visualize the uniform compositions of hybrid photoanodes.

S5 Microstructural analysis and size distribution of synthesized CQDs

Fig. S7 (a) Representative HRTEM image of a CQD with featured (100) crystallite

fringes. (b) Low magnification TEM image of CQDs, showing the uniform size distributions of obtained CQDs. (c) Estimation of correlated size distributions.

S6 Experimental estimation of band structures

Fig. S8 UV-vis absorption spectra and correlated Tauc examination of (a) bare WO_3 NPs, (b) ß-FeOOH NCs and (c) CQDs.

The analyses of band structures are employed by viture of Tauc plot and UPS measurements. The Tauc plot is obtained by plotting $(\alpha h v)^2$ against $h v$ from UV-Vis absorption spectra, followed by determining the intercept of the tangent line with the X-axis in the Tauc plot to determine the Band gap of the material. Here, α represents the absorption coefficient, h is the Planck constant, and ν is the frequency. According to the Tauc plot results, the band gaps of WO_3 , β -FeOOH, and CQDs are found to be 2.76 eV, 2.11 eV, and 2.27 eV, respectively. In addition, UPS analysis is employed to estimate the practical position of the valence band using the following formula [4], $|VB| = hv - (E_{cutoff} - E_R)$ (1) where VB the energy level of valence band, hv the incident photon energy (21.2 eV), E_{cutoff} the energy corresponding to the intersection of extension of vertical line segment and the baseline in the UPS spectrum, E_R the energy corresponding to the intersection

of epitaxial tangent at the initial rise and the baseline. Accordingly, the valence band energies of WO_3 , $B-FeOOH$, and CQDs are measured to be -7.69 eV, -5.96 eV, and -5.82 eV, respectively.

Table S1. Extracted valence band minimum, conduction band maximum and bandgap energy of investigated structures from the interplay of UPS and UV-Vis lightabsorption measurements

		Valence band (eV) Conduction band (eV)	Band gap (eV)
WO ₃	-7.69	-5.16	2.53
β -FeOOH	-5.96	-3.85	2.11
CQDs	-5.82	-3.55	2.27

S7 Analytic XPS spectra of p- $FeOOH@WO_3$ NPs

Fig. S9 Analytic XPS spectra of (a) Fe 2p and (b) W 4f for 0 s, 90 s, 120 s, 150 s of p-FeOOH $@$ WO₃ photoanodes. The results from Fe 2p spectra indicate that, under plasma treatment durations of 0, 90, 120, and 150 s, the ratios of Fe^{2+} to Fe^{3+} are observed to be 1.50, 1.61, 1.82, and 1.11, respectively. These findings are in line with the quantitative evolutions shown in Fig. 4 of main text. Furthermore, the results of the W 4f spectra demonstrate the consistent signals of $W4f_{5/2}$, $W4f_{7/2}$, and $W5p_{3/2}$ of samples with or without experiencing the plasma treatment.

S8 Detailed electrochemical CV examinations

Fig. S10 Electrochemical CV results obtained from the non-Faradic region: (a) Bare WO₃ NPs, (b) FeOOH@WO₃ NPs, (c) p-FeOOH@WO₃ NPs and (d)CQDs/p-FeOOH $@$ WO₃ NPs.

Fig. S11 Comparisons of double layer capacitance (C_{d}) values from four different photoanode designs.

S9 Faradaic efficiency of O_2 and H_2 production in the presence of designed photoanodes

Fig S12 Calculated and measured Faradaic efficiencies at 1.23 V vs. RHE. The results show that after 60 min of water oxidation reaction, the actual yields of hydrogen and oxygen are approximately 35.6 µmol and 17.7 µmol, respectively. In addition, the Faradaic efficiencies for hydrogen and oxygen are estimated to be 89.5% and 88.0%, respectively. highlighting the effectiveness of dual-modification strategies in enhancing water oxidation activity.

S10 Dynamic CV measurement of FeOOH $(5 \text{ mM})@WO_3$ NPs during PEC process

Fig. S13 The dynamic CV measurement of FeOOH $(5 \text{ mM})@WO_3$ NPs during the PEC test. Long-term photoelectrochemical tests of designed photoanodes spanning 0-60 min were conducted [5]. To examine the dynamic changes, the CV results of samples were extracted at every 15 min, with a scan range from 0.8 V to -0.8 V. The results show the consistent oxidation signal at around 0.1 V corresponding to the oxidative conversion of Fe^{2+} states. These findings clearly confirm the existence of Fe^{2+} within electrochemical cycles in all samples.

S11 Morphological characterizations of p-FeOOH $@WO_3$ NPs after conducting PEC tests

Fig. S14 Top-view SEM images of FeOOH $(5 \text{ mM})@WO_3$ NPs (a) before and (b) after 120 s of Ar plasma treatment. Top-view SEM images of p-FeOOH $(5 \text{ mM})@WO_3$ NPs (120 s of plasma treatment) after experiencing (c) 1-hour and (d) 2-hour photoelectrochemical reactions. The results confirm that no obvious morphological variations of photoanodes after experiencing plasma treatment (120 s) and long-term photoelectrochemical tests.

S12 Mott-Schottky test of $FeOOH@WO_3$ NPs before and after plasma treatment

Fig. S15 Measured Mott-Schottky plots of $FeOOH@WO_3$ NPs before and after Ar plasma treatment. The results indicate that without plasma treatment, the flat band potential of FeOOH@WO₃ NPs at p-type side was measured to be 0.11 V, whereas the

flat band potential of plasma-treated photoanodes was decreased to 0.08 V, suggesting the hole transfer from WO3 NPs to FeOOH that causes the reduction of Fermi level due to p-type doping. Along with photoelectrochemical measurements presented in the main text, these results confirm that the emergence of plasma treatment is effective for inducing band bending at interfaces and facilitates the injection and transport of photogenerated holes.

S13 Stability examinations of p-FeOOH $@$ WO₃ NPs with various treatment durations

Fig. S16 Stability examinations of photocurrent density versus time in the presence of p-FeOOH $@WO_3$ photoanode at 1.23 V vs. RHE under the stimulated-light irradiations (100 mW cm⁻²). The outcomes reveal that the p-FeOOH (120 s) $@WO_3$ NPs exhibit a stable photocurrent density over an extended period during the stability assessment. In contrast, the photocurrent density of p-FeOOH (150 s) $@WO_3$ NPs displays significant decrease observed at 8.75 min, indicating that the prolonged plasma treatment may cause the structural degradation of photoanodes. These long-term tests confirm that the emergence of plasma treatment for 120 s represents the optimal solution for both longterm stability and durability.

S14 Comparative table of state-of-art photoanode designs and this work

Table S2 Details of PEC measurements of various photoanode designs

Reference

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